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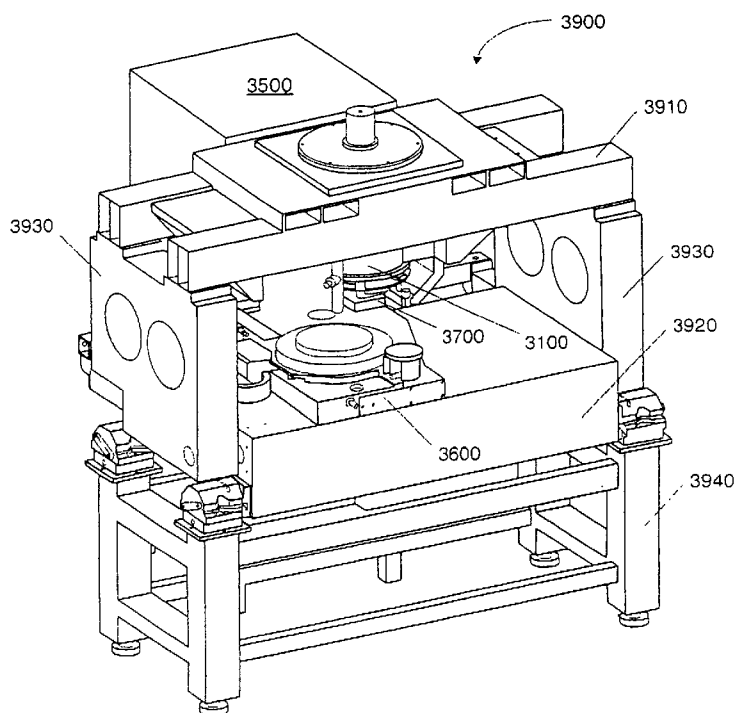
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(54) Title: IMPRINT LITHOGRAPHY PROCESSES AND SYSTEMS



(57) Abstract: Processes of patterning substrates by imprint lithography using an apparatus (3900) including an imprint head (3100), an activating light source (3500), a motion stage (3600), a patterned template (3700), an imprint head support (3910), a motion stage support (3920), bridging supports (3930) and a support table (3940).

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